Studies on Millimeter-band Low-Voltage Traveling-Wave Tubes with Planar Meander-Line Slow-Wave Structures

Andrei Starodubov, Anton Pavlov, Viktor Galushka, Alexey Serdobintsev, Ilva Kozhevnikov

Saratov State University Saratov, Russia, 410012

Roman Torgashov, Andrey Rozhnev, Nikita Ryskin

Saratov Branch, Institute of Radio Engineering and Electronics RAS Saratov, Russia, 410019

Abstract: We have designed D-band planar meander-line slow wave structure for low voltage compact traveling-wave tubes (TWTs) with sheet electron beam. The designed Dband slow wave structure was microfabricated by magnetron sputtering and picoseconds laser ablation. We further develop our approach for planar slow wave structure microfabrication based on magnetron sputtering and laser ablation processes. Transmission and reflection losses of proposed SWS were measured experimentally and evaluated numerically. The experimental results are in good agreement with the numerical ones.

Keywords: Traveling-wave tube; slow-wave structure; Wband; D-band; microfabrication; laser ablation; numerical modeling.

Introduction

Small-sized, high-power vacuum power amplifiers and oscillators operating at millimeter and submillimeter (THz) bands are of great interest for applications in security, non-destructive evaluation, ultra-high-speed information and communication systems, radio astronomy, spectroscopy, medicine, etc. [1,2]. In particular, promising planar slow-wave structures (SWS) utilizing a metallized microstrip line on a dielectric substrate structure have been proposed [3-7]. In [8-10], we reported the results of development of V-band (50-70 GHz) planar meander-line SWS. Such SWSs have high slow-down factor, $c/v_{ph} \sim 5-10$, and thus, are suitable for use in low-voltage traveling-wave tubes (TWTs). Among their other advantages, there are compatibility with the microfabrication technologies, and ability to accommodate a high-aspect-ratio sheet electron beam.

This paper present the results of research aimed at development of TWTs with the meander-line SWS operating at higher-frequency W- and D-band.

Dmitry Bessonov

Saratov State Technical University Saratov, Russia, 410077

Sergei Molchanov, Igor Bakhteev

Central Institute of Measurement Equipment Saratov, Russia, 410002

Giacomo Ulisse, Viktor Krozer

Goethe University Frankfurt Frankfurt am Main, Germany, 60323

SWS Fabrication and Characterization

The W- and D-band planar microstrip SWSs on a quartz substrate were designed and their electromagnetic parameters were evaluated using the finite-element COMSOL Multiphysics simulator. For fabrication of the SWSs, we have developed a cheap, fast, and flexible technology [8-10] based on magnetron sputtering of a metallic film over a substrate and subsequent forming of an SWS pattern by using a computer-numerical-control (CNC) laser ablation. At the final stage the microfabrication process, the substrate is cut into individual SWS samples by using a high-precision diamond scriber with manual positioning.

Using an ytterbium fiber laser with a 1.064-um wavelength and 10-ns pulse duration, we successfully fabricated the Wband structures. However, for fabrication of smaller-size Dband structures, we have to improve the microfabrication process by utilizing the picosecond ablation instead of the nanosecond one. A 10- μ m thick copper film was deposited onto 0.2-mm thickness quartz plate by magnetron sputtering. An ytterbium pulse laser with wavelength of 1050-1070 nm and 10-ps pulse duration is used for SWS patterning. Fig. 1 shows a photo of the fabricated D-band SWS and its scanning-electron-microscopy (SEM) image.

The ZVA40 vector network analyzer (Rohde&Schwarz) with frequency converters that convert the frequency range of the vector network analyzer to either W- or D-band is used for the cold-test measurements. Good transmission characteristics values were obtained. The transmission loss S21 of the full-length SWS does not exceed -5 dB while the reflection loss is less than -10 dB. Experimentally measured *S*-parameters are in good agreement with the numerical ones.

Gain Calculations

For the numerical calculations, we use the 1-D nonlinear frequency-domain code [11]. The W-band TWT with a 0.1-A sheet electron beam and 1-cm length SWS was designed

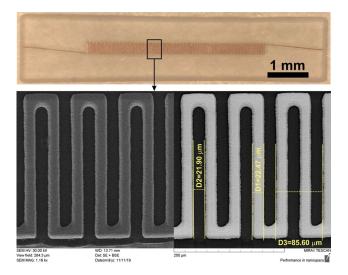


Figure 1. Photo of the fabricated SWS and its enlarged fragment made by scanning electron microscopy in SE and BSE regimes.

and simulated. The simulation predicts over 20 dB smallsignal gain and over 80 W power at saturation. The operating beam voltage does not exceed 6 kV. However, owing to strong dispersion of the SWS, the -3-dB gain bandwidth is rather narrow, $\sim 3-5$ GHz. On the other hand, the central frequency may be easily tuned from 80 to 100 GHz by varying the beam voltage (cf. 8).

For the D-band TWT with 50-mA beam current and 1.75cm length, up to 27-dB gain is predicted, and the power may exceed 25 W. The results of simulation are presented in Fig. 2.

Acknowledgements

This research is supported by the Cooperative Grant of Russian Foundation for Basic Research (grant 20-57-12001) and DFG (grant 430109039).

References

- J.H. Booske et al., "Vacuum Electronic High Power Terahertz Sources," in IEEE Transactions on Terahertz Science and Technology, vol. 1, no. 1, pp. 54-75, Sept. 2011.
- J.I. Kim, S.G. Jeon, and G.S. Park, "Terahertz vacuum electronics," in Handbook of Terahertz Technologies: Devices and Applications, H.-J. Song and T. Nagatsuma, Eds. Boca Raton, FL, USA: CRC Press, ch. 8, pp. 187–220, 2015
- M. Sumathy, D. Augustin, S.K. Datta, L. Christie, and L. Kumar, "Design and RF characterization of W-band meander-line and folded-waveguide slow-wave structures for TWTs," IEEE Trans. Electron Devices, vol. 60, no. 5, pp. 1769-1775, May 2013.
- S. Wang and S. Aditya, "A microfabricated V-shaped microstrip meander-line slow-wave structure," IEEE Trans. Electron Devices, vol. 60, no. 3, pp. 1251-1256, March 2013.
- A.I. Benedik, A.G. Rozhnev, N.M. Ryskin, G.V. Torgashov, N.I. Sinitsyn, N.A. Bushuev, and P.D. Shalaev, "Study of electrodynamic parameters of the planar meander slow-wave structures for THz band traveling wave tubes," in 16th IEEE International Vacuum Electronics Conference (IVEC 2015),

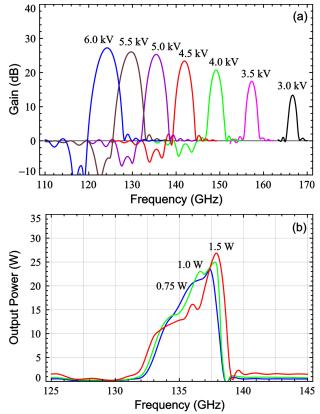


Figure 2. Small-signal gain versus frequency at different beam voltages (a) and output power versus frequency at 5.0-kV beam voltage and different driving powers (b).

Beijing, China, 27-29 April, 2015. doi: 10.1109/IVEC.2015.7223750

- C. Ding, Y. Wei, Q. Li, L. Zhang, G. Guo, and Y. Gong, "A dielectric-embedded microstrip meander line slow-wave structure for miniaturized traveling wave tube," J. Electromag. Waves Appl., vol. 31, no. 17, pp. 1938-1946, October 2017.
- G. Ulisse and V. Krozer, "W-band traveling wave tube amplifier based on planar slow wave structure," IEEE Electron Device Letters, vol. 38, no.1, pp. 126-129, Jan. 2017.
- N.M. Ryskin, A.G. Rozhnev, A.V. Starodubov, A.A. Serdobintsev, et al., "Planar microstrip slow-wave structure for low-voltage Vband traveling-wave tube with a sheet electron beam," IEEE Electron Device Letters, vol. 39, no. 5, pp. 757-760, May 2018.
- A.V. Starodubov, A.A. Serdobintsev, A.M. Pavlov, V.V. Galushka, D.M. Mitin, and N.M. Ryskin, "A novel microfabrication technology of planar microstrip slow-wave structures for millimeter-band traveling-wave tubes," 2018 IEEE International Vacuum Electronics Conference (IVEC), Monterey, CA, 2018, pp. 333-334.
- N.M. Ryskin, A.G. Rozhnev, A.V. Starodubov, A.A. Serdobintsev, R.A. Torgashov, V.V. Galushka, and A.M. Pavlov, "Development of planar slow-wave structures for low-voltage millimeter-band vacuum tubes," 2018 43rd International Conference on Infrared, Millimeter, and Terahertz Waves (IRMMW-THz), Nagoya, Japan, 9-14 Sept. 2018. doi: 10.1109/IRMMW-THz.2018.8510125.
- T.A. Karetnikova, A.G. Rozhnev, N.M. Ryskin, A.E. Fedotov, S.V. Mishakin, and N.S. Ginzburg, "Gain analysis of a 0.2-THz traveling-wave tube with sheet electron beam and staggered grating slow wave structure," IEEE Trans. Electron Devices, vol. 65, no. 6, pp. 2129-2134, June 2018.